

Supporting Information

In situ monitoring of non-thermal plasma cleaning of surfactant encapsulated nanoparticles

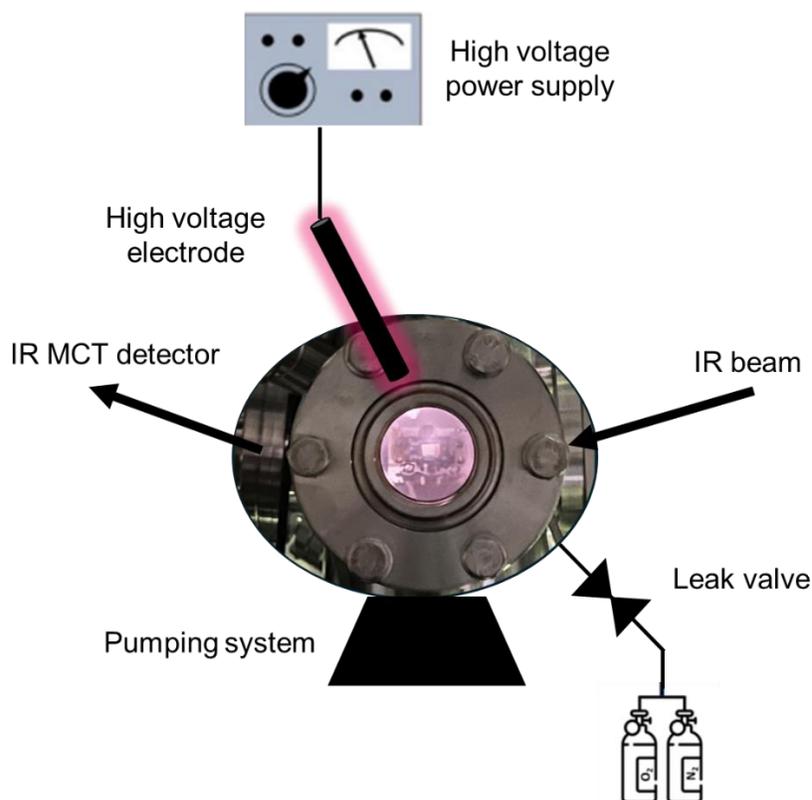
Gengnan Li,^{a*} Dmitri N. Zakharov,^a Sanyatani Skider,^{a,b} Yixin Xu,^{a,b}, Xiao Tong,^a Panagiotis
Dimitrakellis^c, Jorge Anibal Boscoboinik^{a*}

^a Center for Functional Nanomaterials, Brookhaven National Laboratory, Upton, New York 11973, United States

^b Department of Materials Science and Chemical Engineering, Stony Brook University, Stony Brook, New York
11790, United States

^c Catalysis Center for Energy Innovation, University of Delaware, Newark, Delaware 19716, United States;
Department of Chemical and Biomolecular Engineering, University of Delaware, Newark, Delaware 19716, United
States

*Corresponding author: G. Li (gli2@bnl.gov); J.A. Boscoboinik (E-mail: jboscooinik@bnl.gov)



Scheme 1. Plasma setup in IRRAS.

Ex situ UV-ozone treatment

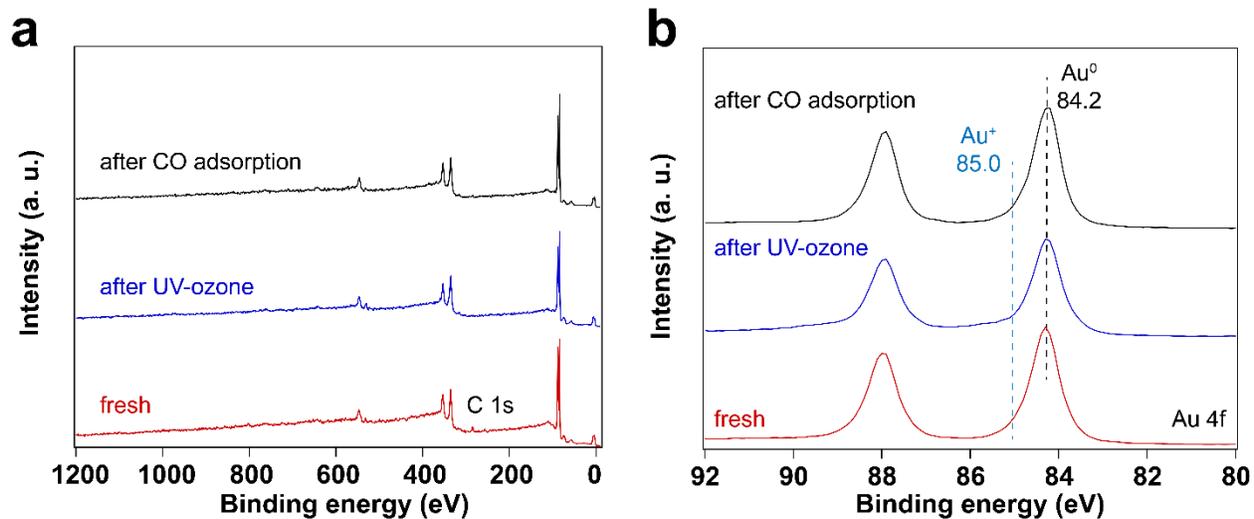


Figure S1. (a) Survey spectra and (b) Au 4f XP spectra of surfactant encapsulated Pt nanoparticles before and after UV-ozone treatment and after in situ CO adsorption experiment.

Table S1. Surface composition of Pt nanoparticles deposited on Au film derived from high-resolution XPS spectra.

Area ratio	C1s/Au4f	O1s/Au4f	N1s/Pt4f	Pt4f/Au4f
Fresh sample	0.83	0.27	0.17	0.08
After UV-ozone treatment	0.12	0.35	-	0.09
After CO adsorption experiment	0.02	0.13	-	0.05

In situ CO adsorption on Pt nanoparticles after UV-ozone treatment

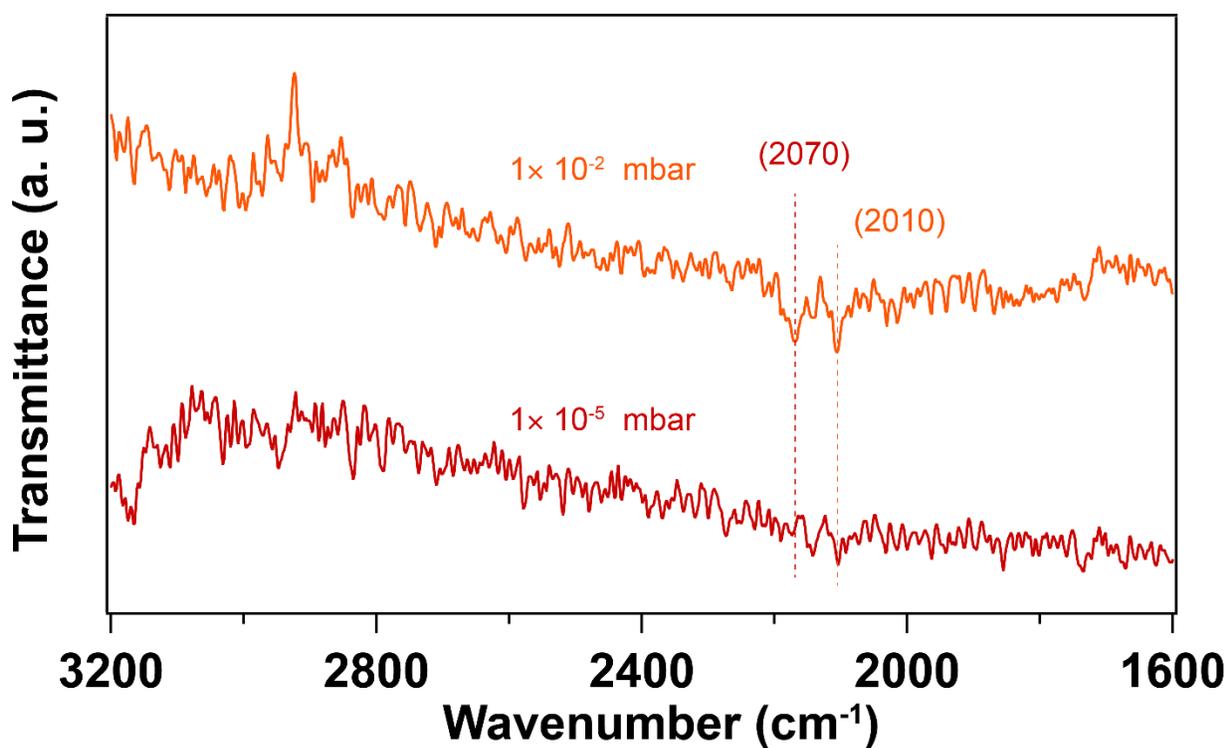


Figure S2. IRRAS spectra of in situ CO adsorption on surfactant encapsulated Pt nanoparticles after UV-ozone treatment. It shows CO adsorption on Pt-O sites with vibrational frequencies of 2170 and 2110 cm⁻¹.

In situ O₂ plasma treatment

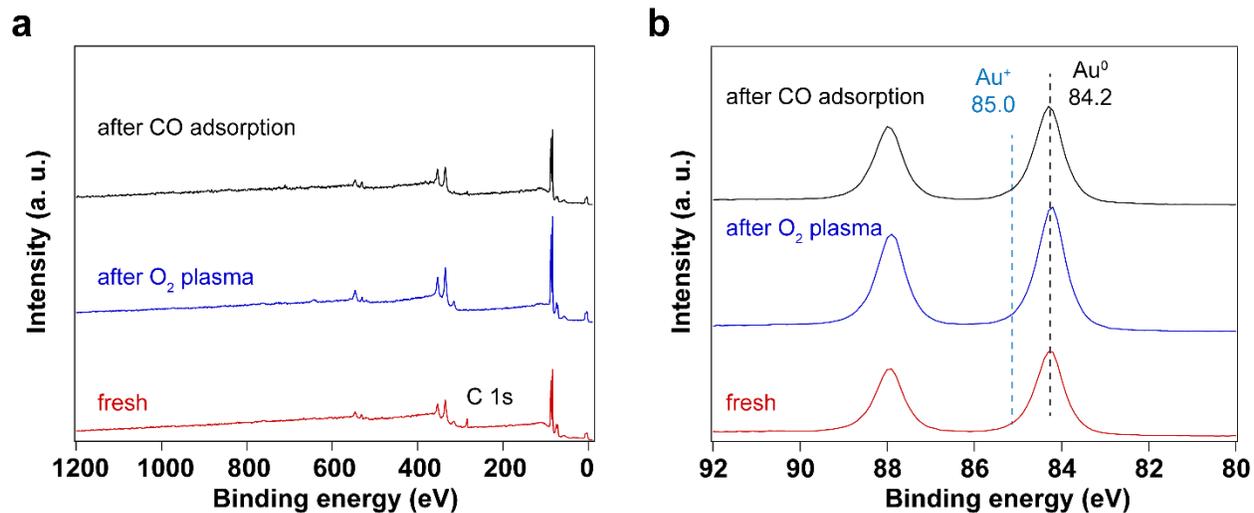


Figure S3. (a) Survey spectra and (b) Au 4f XP spectra of surfactant encapsulated Pt nanoparticles before and after O₂ plasma treatment.

Table S2. Surface composition of Pt nanoparticles deposited on Au film derived from high-resolution XPS spectra.

Area ratio	C1s/Au4f	O1s/Au4f	N1s/Pt4f	Pt4f/Au4f
Fresh sample	1.83	0.50	0.16	0.30
After O ₂ plasma treatment	0.01	0.29	0.01	0.25

In situ H₂ plasma treatment

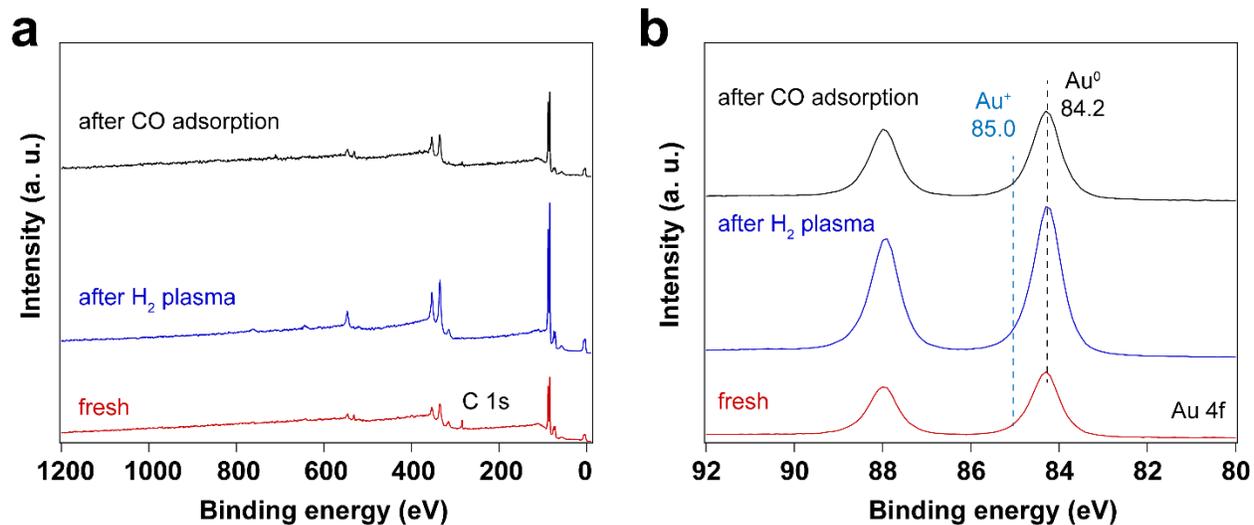


Figure S4. (a) Survey spectra and (b) Au 4f XP spectra of surfactant encapsulated Pt nanoparticles before and after H₂ plasma treatment.

Table S3. Surface composition of Pt nanoparticles deposited on Au film derived from high-resolution XPS spectra.

Area ratio	C1s/Au4f	O1s/Au4f	N1s/Pt4f	Pt4f/Au4f
Fresh sample	2.08	0.52	0.43	0.31
After H ₂ plasma treatment	0.86	0.06	0.06	0.18

Ex situ UV-ozone treatment followed by in situ H₂ reduction at 100 °C

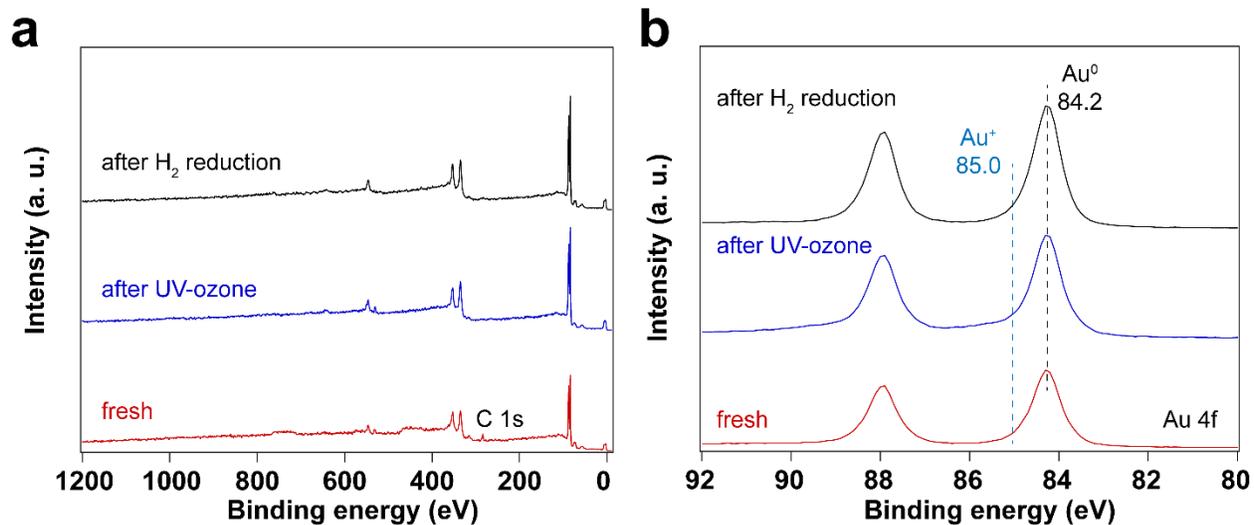


Figure S5. (a) Survey spectra and (b) Au 4f XP spectra of surfactant encapsulated Pt nanoparticles before and after UV-ozone and H₂ plasma treatment.

Table S4. Surface composition of Pt nanoparticles deposited on Au film derived from high-resolution XPS spectra.

Area ratio	C1s/Au4f	O1s/Au4f	N1s/Pt4f	Pt4f/Au4f
Fresh sample	1.25	0.37	0.17	0.11
After UV-ozone treatment	0.13	0.30	-	0.07
After H₂ reduction	0.20	0.06	0.05	0.07

In situ O₂ plasma followed by H₂ plasma treatment

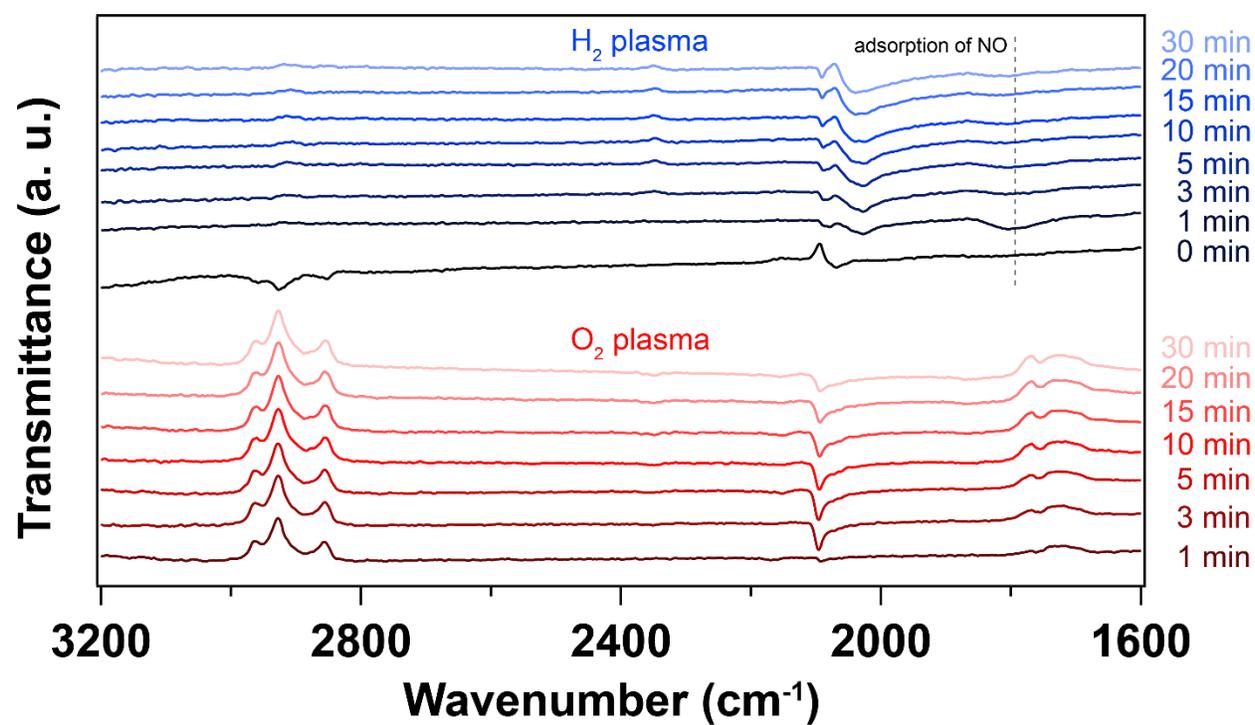


Figure S6. IRRAS spectra of surfactant encapsulated Pt nanoparticles by sequential O₂-H₂ plasma treatment. The pressure of O₂ or H₂ was 0.1 mbar, power applied for plasma treatment was 4 W.

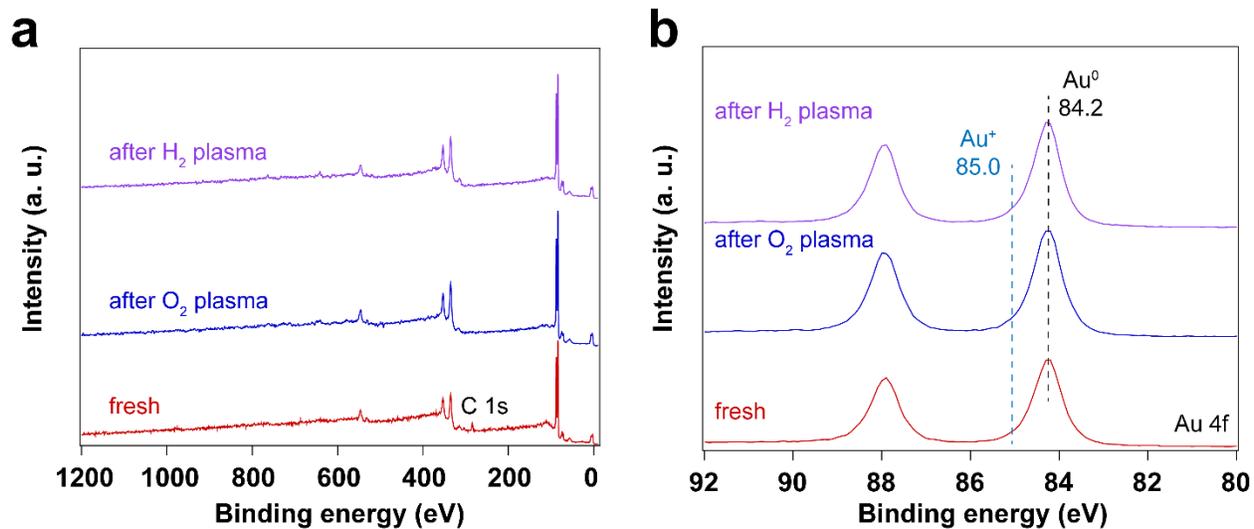


Figure S7. (a) Survey spectra and (b) Au 4f XP spectra of surfactant encapsulated Pt nanoparticles before and after O₂ and H₂ plasma treatment.

Table S5. Surface composition of Pt nanoparticles deposited on Au film derived from high-resolution XPS spectra.

Area ratio	C1s/Au4f	O1s/Au4f	N1s/Pt4f	Pt4f/Au4f
Fresh sample	1.33	0.26	0.14	0.08
After O₂ plasma treatment	0.03	0.26	-	0.11
After H₂ plasma treatment	0.07	0.12	-	0.16

Scanning electron microcopy analysis of Pt nanoparticles on Au substrate

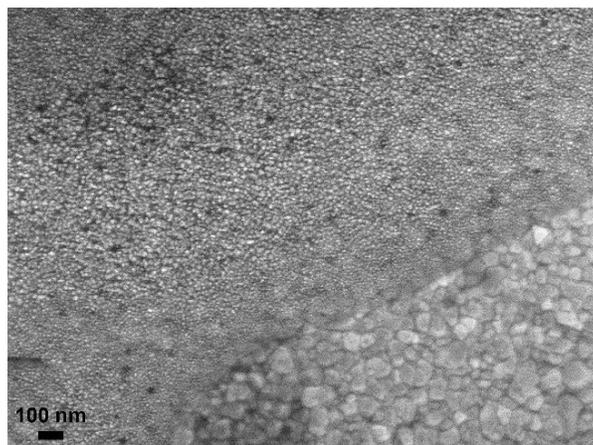


Figure 8. SEM image of fresh surfactant encapsulated Pt nanoparticles on Au film.

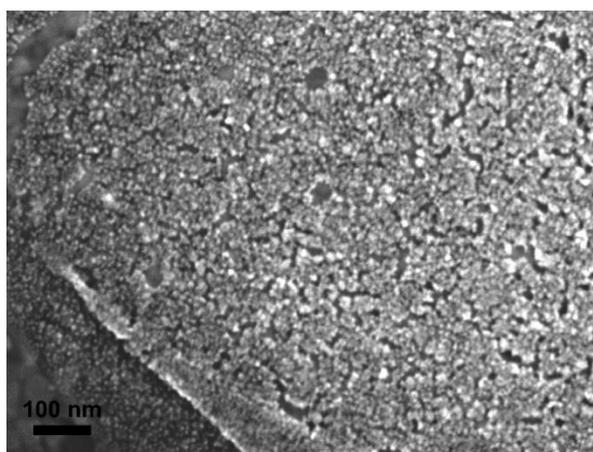


Figure S9. SEM image of surfactant encapsulated Pt nanoparticles on Au film after UV-ozone treatment.

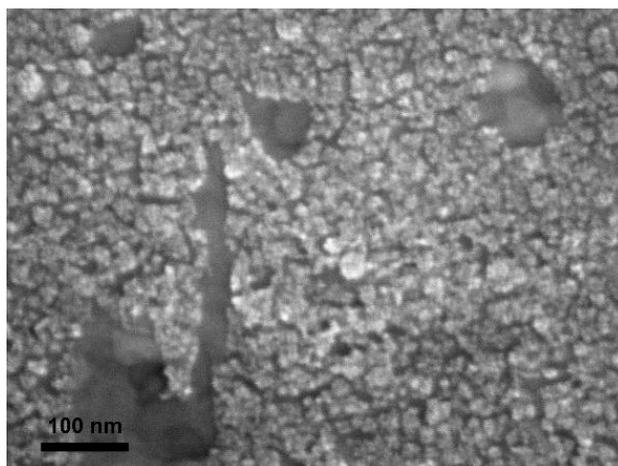


Figure S10. SEM image of surfactant encapsulated Pt nanoparticles on Au film after UV-ozone treatment followed by H₂ reduction at 100 °C.

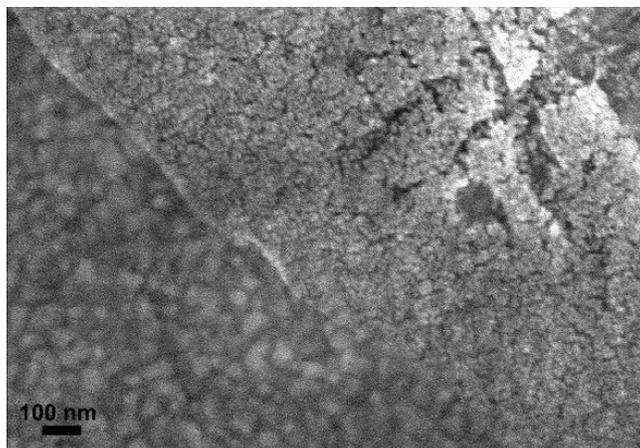


Figure S11. SEM image of surfactant encapsulated Pt nanoparticles on Au film after O₂ plasma treatment.

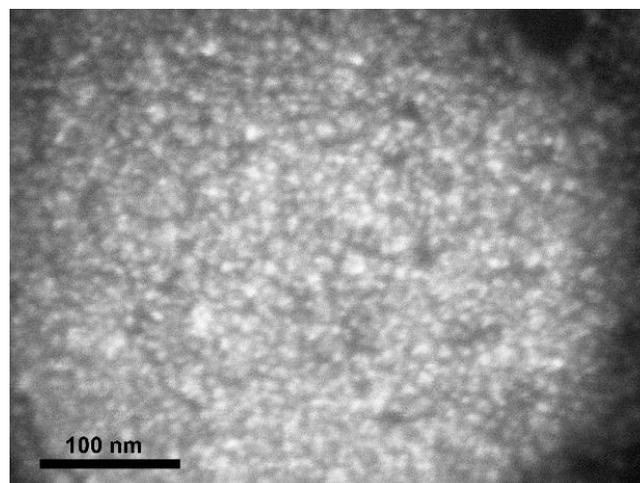


Figure S12. SEM image of surfactant encapsulated Pt nanoparticles on Au film after H₂ plasma treatment.

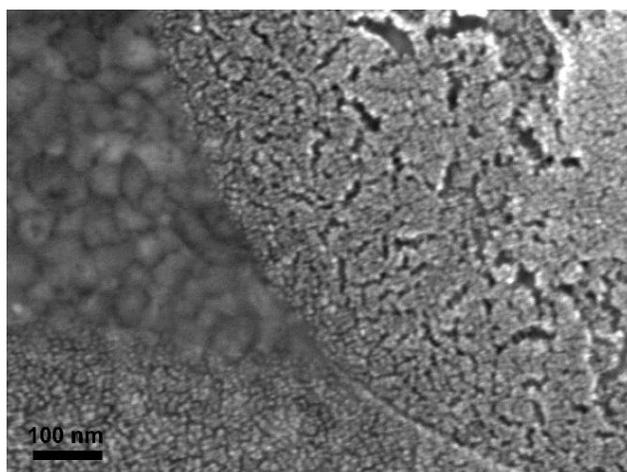


Figure S13. SEM image of surfactant encapsulated Pt nanoparticles on Au film after O₂ plasma treatment followed by H₂ plasma treatment.

Atomic force microscopy analysis of Pt nanoparticles on Au substrate

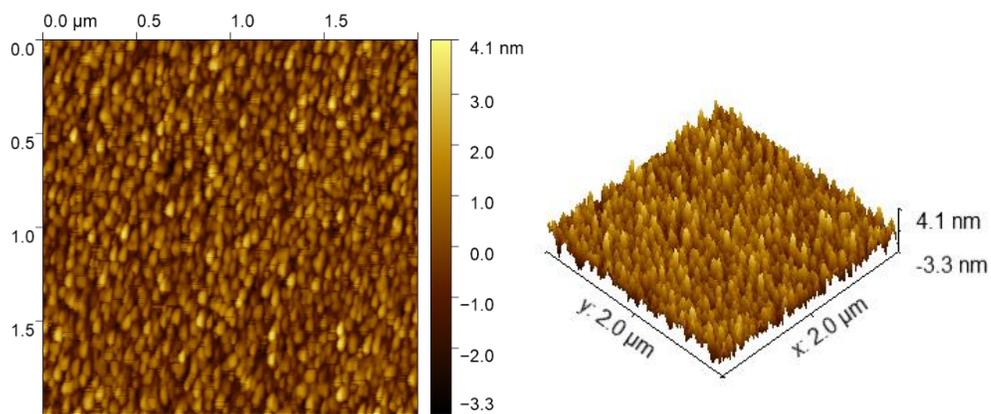


Figure S14. Atomic force microscopy (AFM) image of Au substrate.

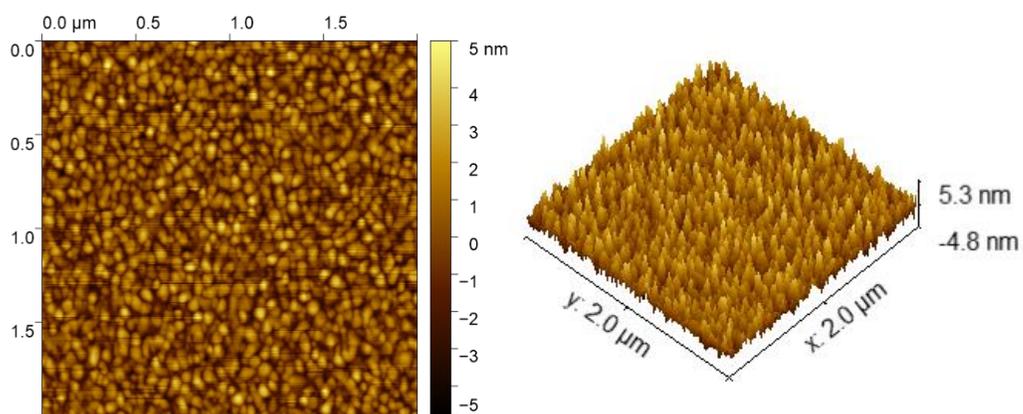


Figure S15. Atomic force microscopy (AFM) image of surfactant encapsulated Pt nanoparticles on Au substrate.

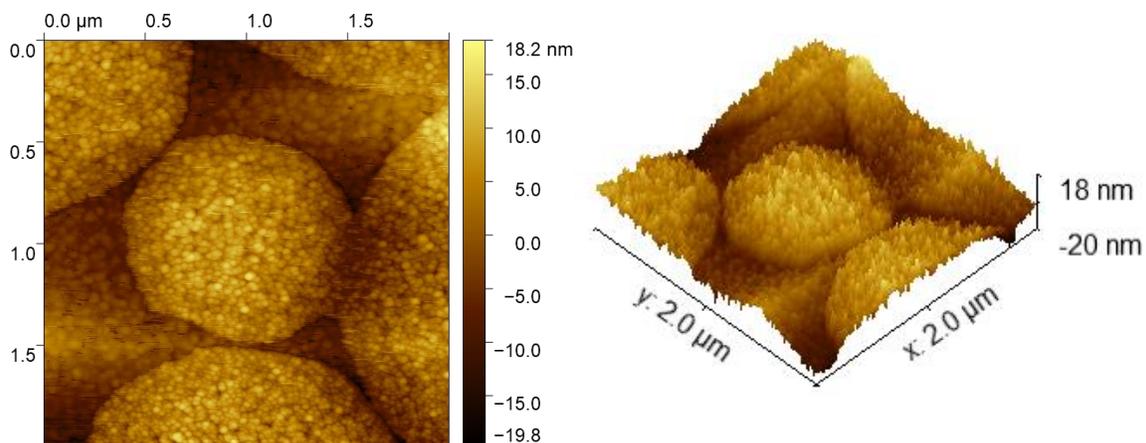


Figure S16. Atomic force microscopy (AFM) image of surfactant encapsulated Pt nanoparticles on Au substrate after thermal treatment under O_2 .

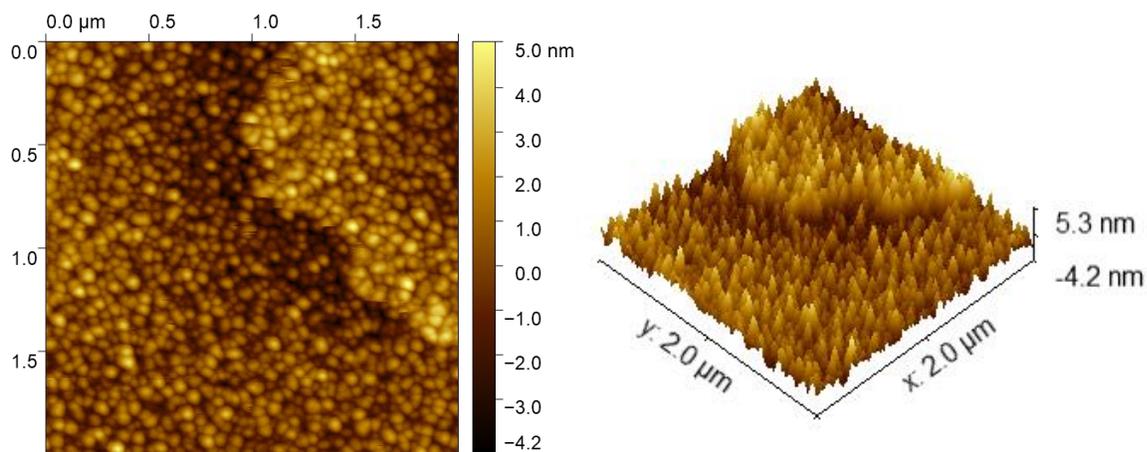


Figure S17. Atomic force microscopy (AFM) image of surfactant encapsulated Pt nanoparticles on Au substrate after H_2 plasma treatment.

In situ CO adsorption on surfactant encapsulated Pt nanoparticles

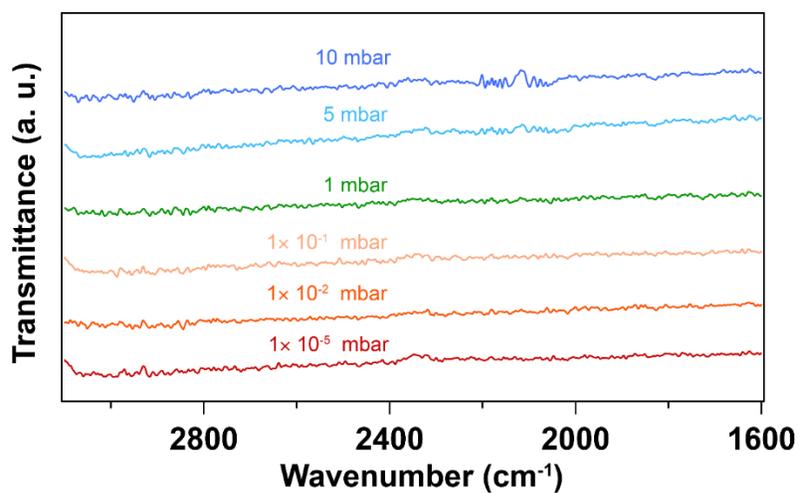


Figure S18. IRRAS spectra of in situ CO adsorption on surfactant encapsulated Pt nanoparticles.

Optical emission spectroscopy (OES) in H_2 plasma

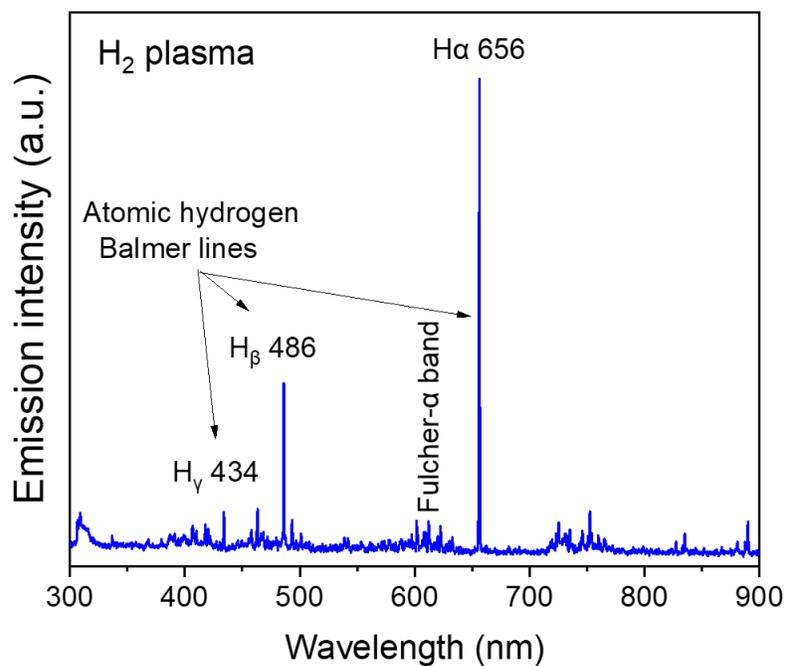


Figure S19. Optical emission spectrum of H₂ plasma used for the removal of surfactants from Pt nanoparticles. The atomic H Balmer lines as well as the Fulcher-a band are dominating the emission spectrum.[1]

[1] N. Škoro, N. Puač, S. Lazović, U. Cvelbar, G. Kokkoris, E. Gogolides, Characterization and global modelling of low-pressure hydrogen-based RF plasmas suitable for surface cleaning processes, *Journal of Physics D: Applied Physics*, 46 (2013) 475206.